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IPPW 2006

***Extreme Temperature/Radiation Tolerant
Crystal Oscillator for High Reliability &
Space Applications***

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Extreme Temperature Frequency Control

- **Working on technologies that serve**
 - **Missions to Venus**
 - Extreme high temperature to 460~470 °C
 - High pressure to 90 bar
 - Shock and vibration
 - Total dose exposure
 - **Missions to Mars and Moon**
 - Extreme low temperatures to -180 ~ - 200°C
 - Large number of thermal cycles (≥ 1500)
 - Shock and vibration
 - Total dosage exposure
- **Solutions for the above have significant synergy with**
 - **Oil and gas exploration, geothermal well operation and instrumentation used in nuclear reactor environment**
 - High temperature to 350 °C
 - High pressure to 1500 bar
 - High shock and vibration
 - Thermal cycles ≥ 100
 - Very long operating life under the combined effects of the extreme environment
- **FMI has its activities focused on solving the problems in these areas and to deliver better solutions for other typical high reliability and space applications**



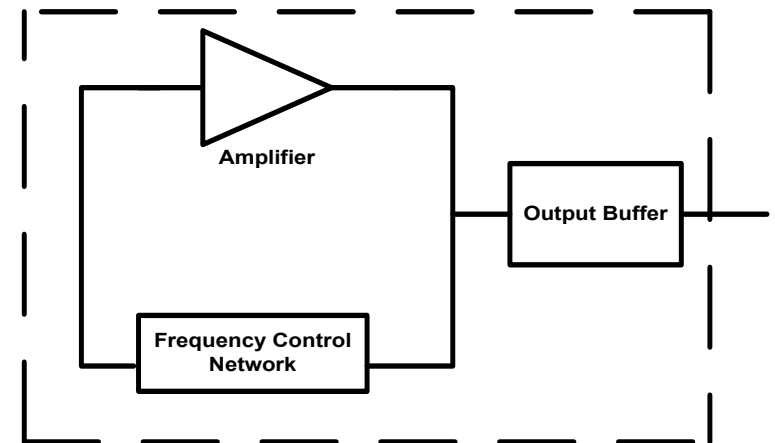
NASA SBIR II Project Objectives

- Development of integrated crystal oscillator solutions for
 1. Extreme low operating temperature from -180°C to $+125^{\circ}\text{C}$
 - Miniaturized, very small outline, low profile
 - Surface mountable
 - Radiation tolerant
 2. Extreme high operating temperature from -55°C to $+460^{\circ}\text{C}$
 - High ambient pressure (90 Bar)
 - Radiation tolerant
 - Surface mount



Other Attributes

- Both solution needs to be rugged, scalable, and commercially available to be used in space applications and other demanding requirements such as down-hole and geothermal instruments
- In either case, the areas to address are:
 - package definition
 - Resonator design
 - Active device (crystal driver)
 - Interconnect scheme
 - Integration/fabrication
 - Testing

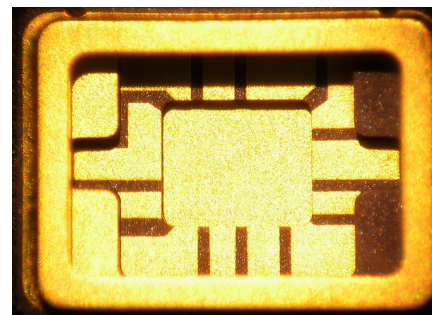


Simplified Oscillator Block Diagram



Miniature 5X7mm Ceramic Package

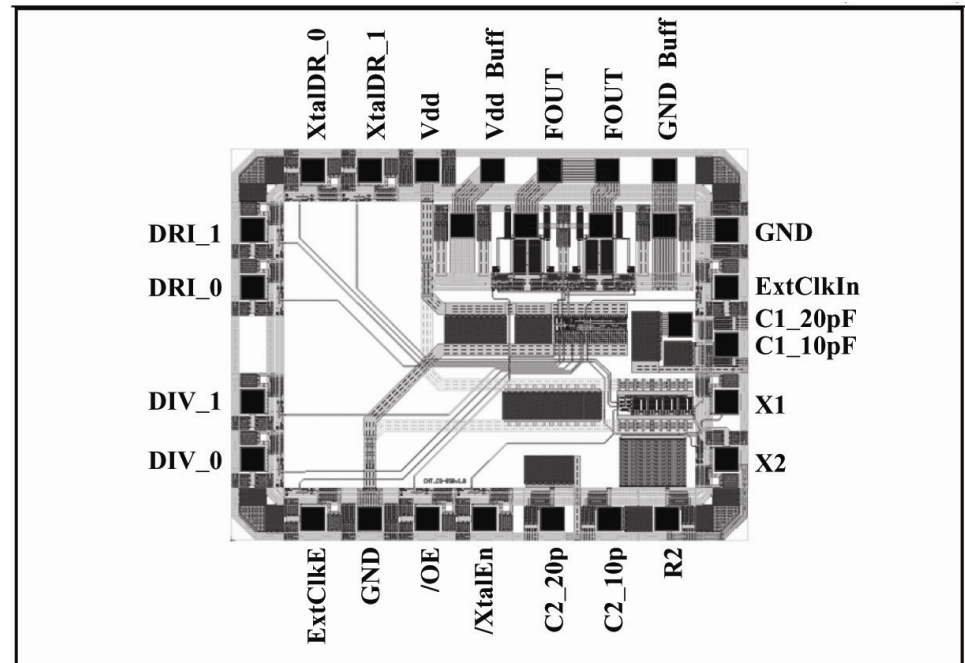
- Industry standard size 5 x 7 mm
- Same size package for Crystal oscillator or resonator only
- Same oscillator housing to allow for different IC integration to handle different temperature ranges
- Adaptable for very high shock applications
- Address both the space applications and high temperature requirements to 200°C
- Multi-conductors layer structure





Extreme Low Temperature Design Approach

- **Single IC solution**
 - SOI technology for radiation tolerance and stable performance over wide temperature range
 - Resonator drive level options for various crystal frequencies
 - Provisions to reach low output frequencies and in-circuit automatic testing
 - Dimensional fit to the package size

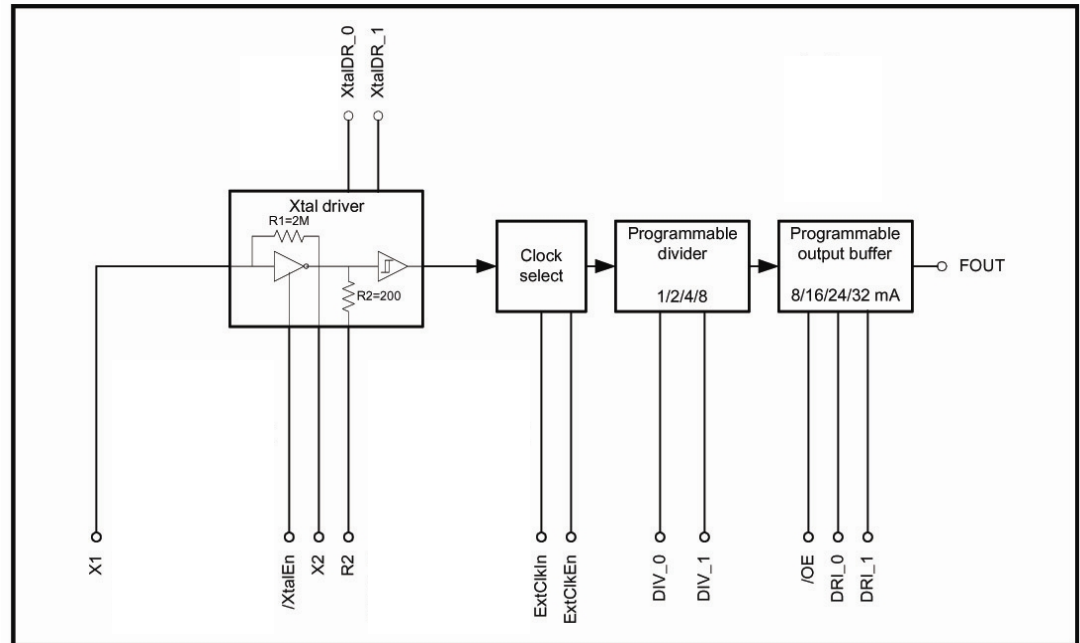




Extreme Low Temperature Design Methodology

- **Oscillator IC**

- Implemented based on the Pierce configuration
- Fabricated on X-Fab. SOI process
- Die size of 85x65 mils fits well in the package cavity
- Sample ICs were separately tested for 1000 hours at 125°C as a reference point
- Single IC → better reliability for existing applications
- In 5X7 SMD, reduces footprint by 7 times compared to standard flat-packs
- Can be used with larger packages as well



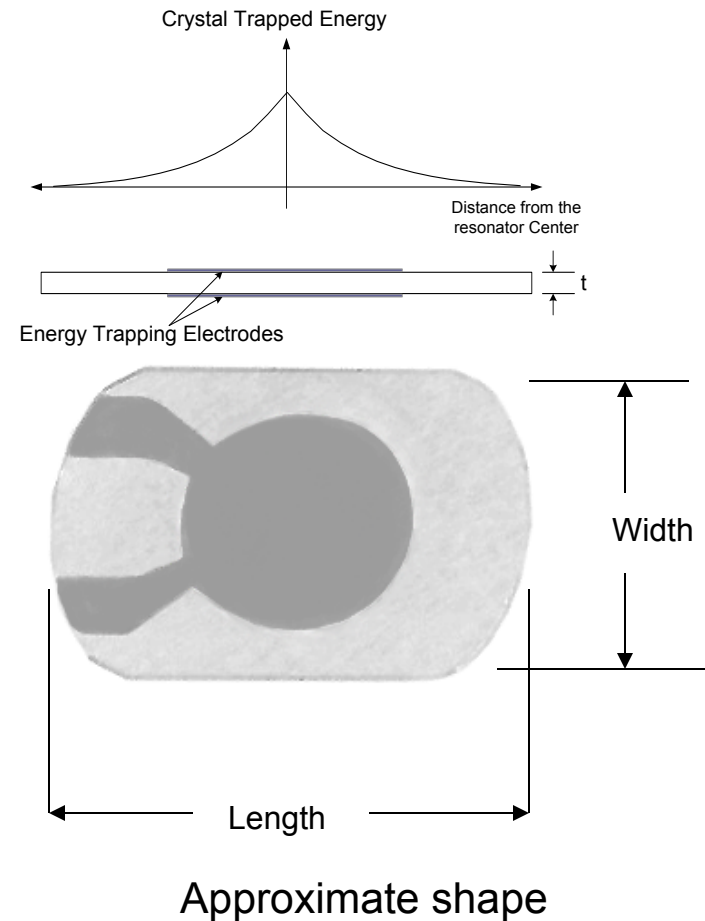
IC Block Diagram



Extreme Low Temperature Design Approach

• Resonator Design

- Blank dimensions optimized to avoid residual trapped energy at the edge
- Wide frequency range from 8MHz to 50+ MHz on the fundamental mode
- Higher frequencies from 30 MHz to 110 MHz on the 3rd overtone mode
- Very high Q quartz bar material, with excellent surface smoothness
- Can be fabricated in small or large volume

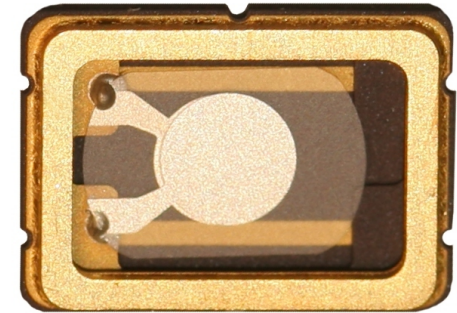
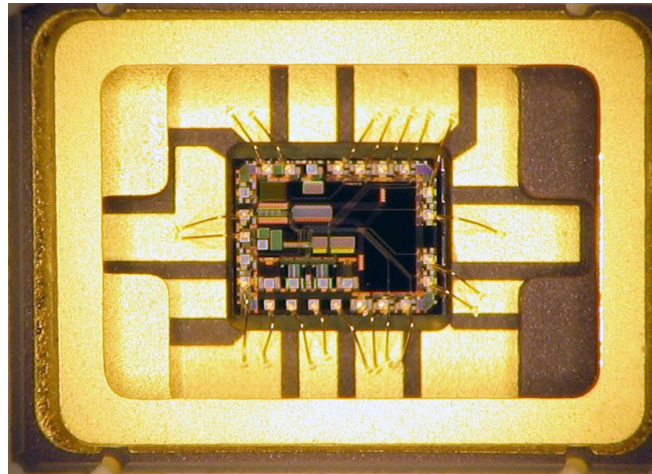




Integration of the Extreme Low Temperature Assembly

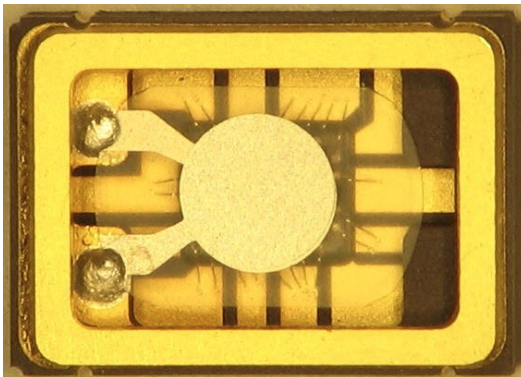
Oscillators

- 5 x 7 ceramic SMD from 500 KHz to 50 MHz
- Packages developed for alternative ICs required for different temp range, and radiation tolerance
- Single IC solution → higher reliability



Crystal resonator

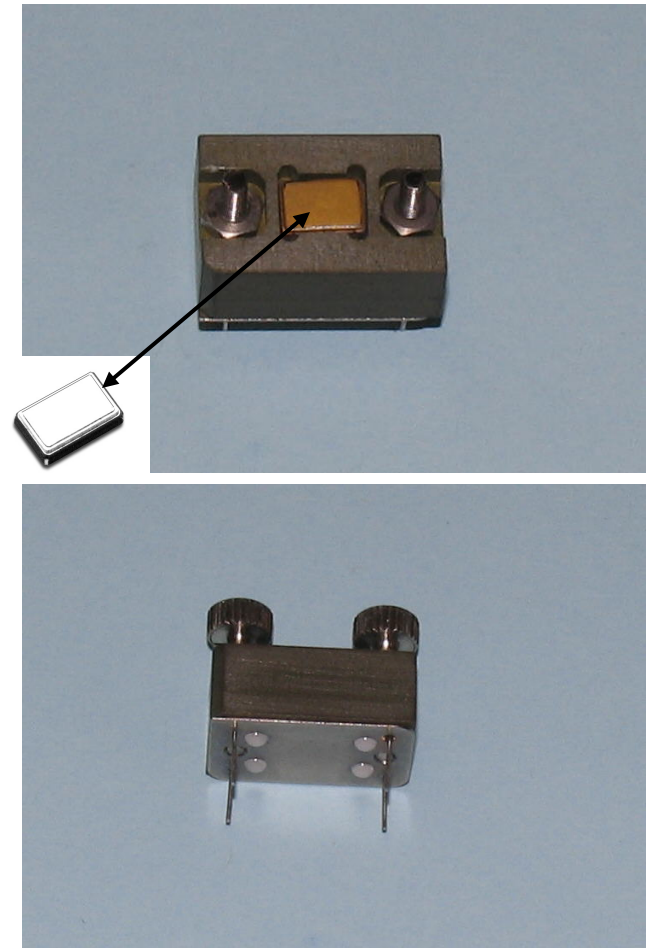
- 5x7mm SMD from 8 to 110 MHz single rotation
- Double rotation cuts in testing stage
- Longitudinal mode elimination by design
- miniature resonators more suitable for random vibration





Testability Provisions

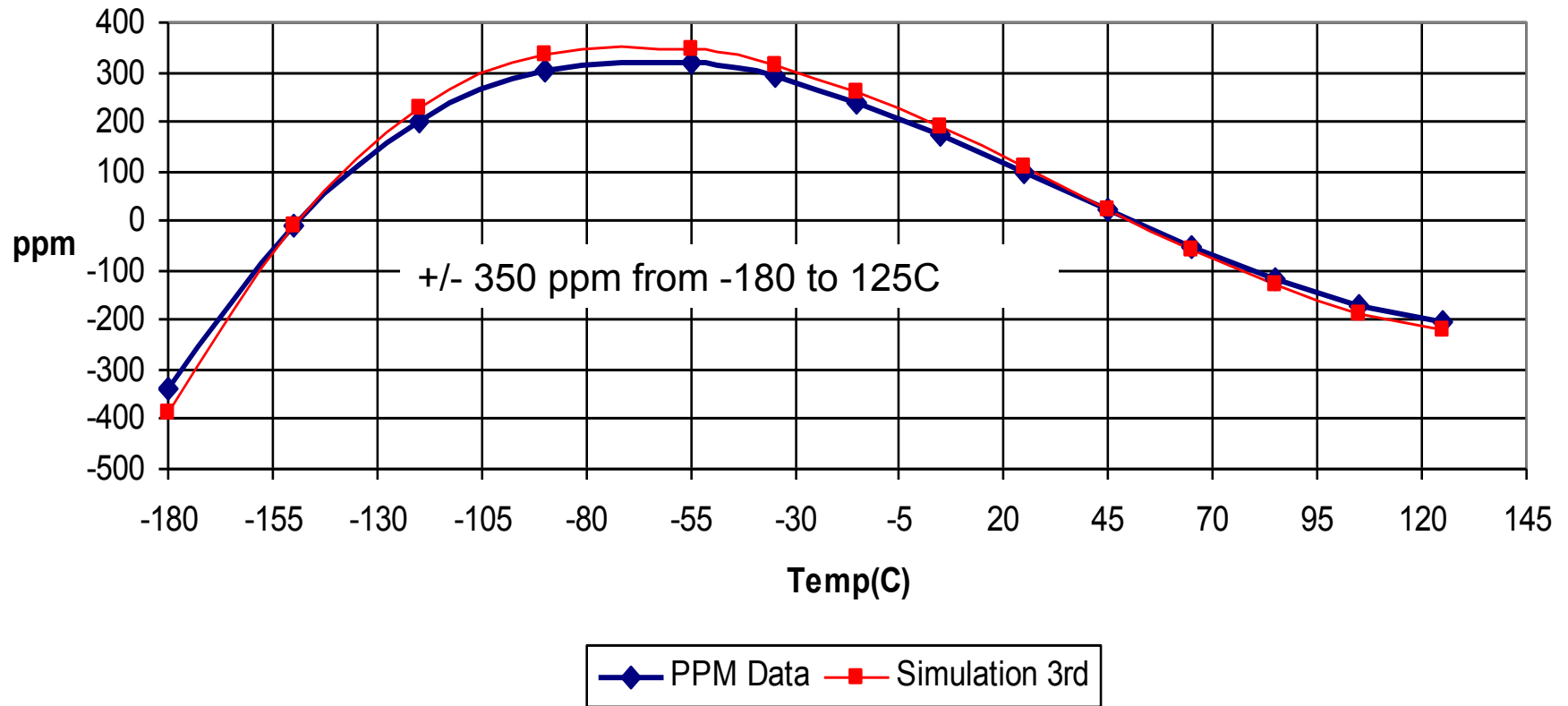
- Developed very rugged test fixtures to handle very large temperature ranges
- Can be used directly or can be added as an adaptor in an existing test socket and be used on test boards already made for standard DIP packages
- Fixtures will last a long time and will be used in various stages of manufacturing and testing such as final precision frequency adjusting, both interim and final electrical testing, as well as burn-in





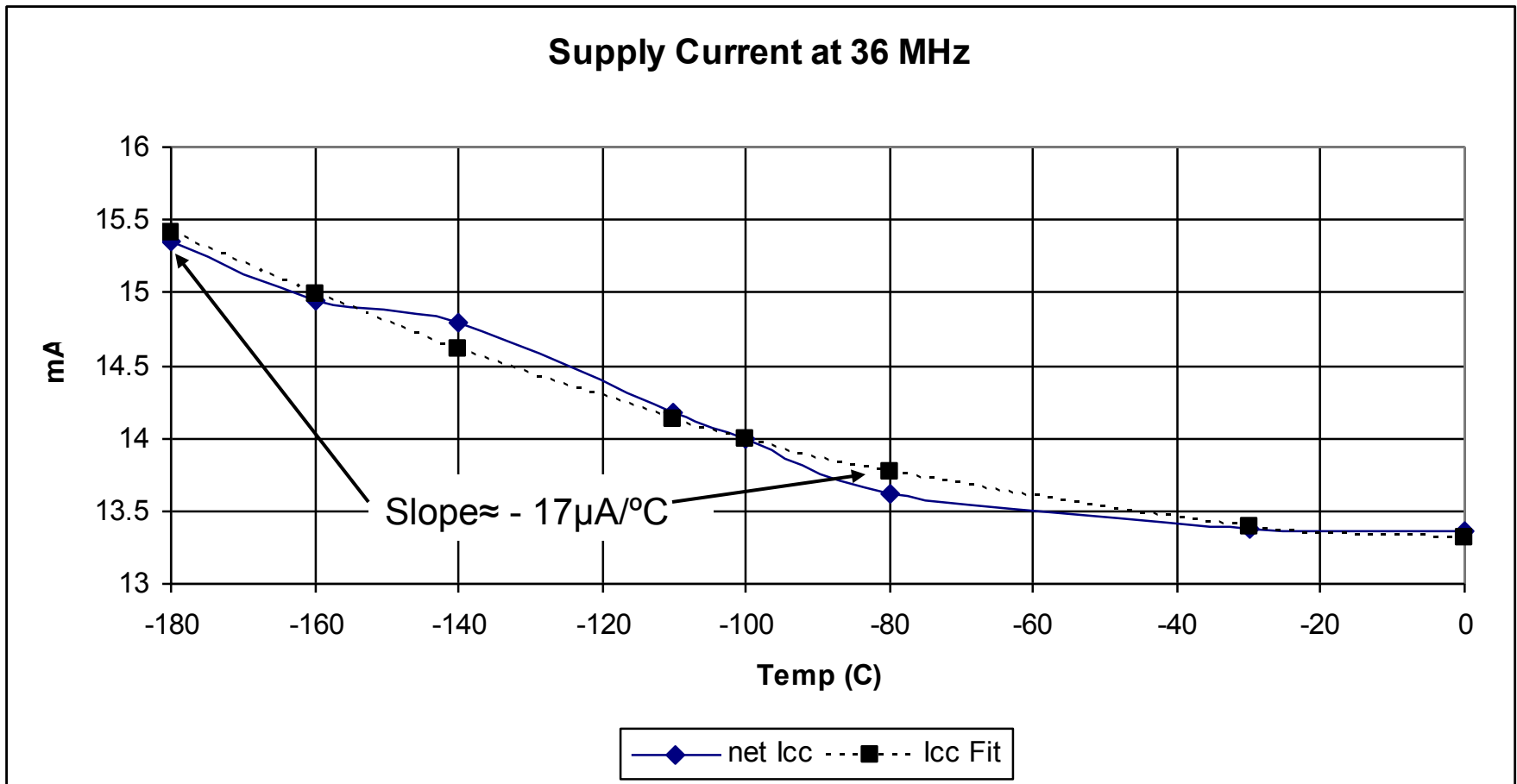
Extreme Low Temperature Frequency Stability Data

32.768 MHz 5X7mm XO





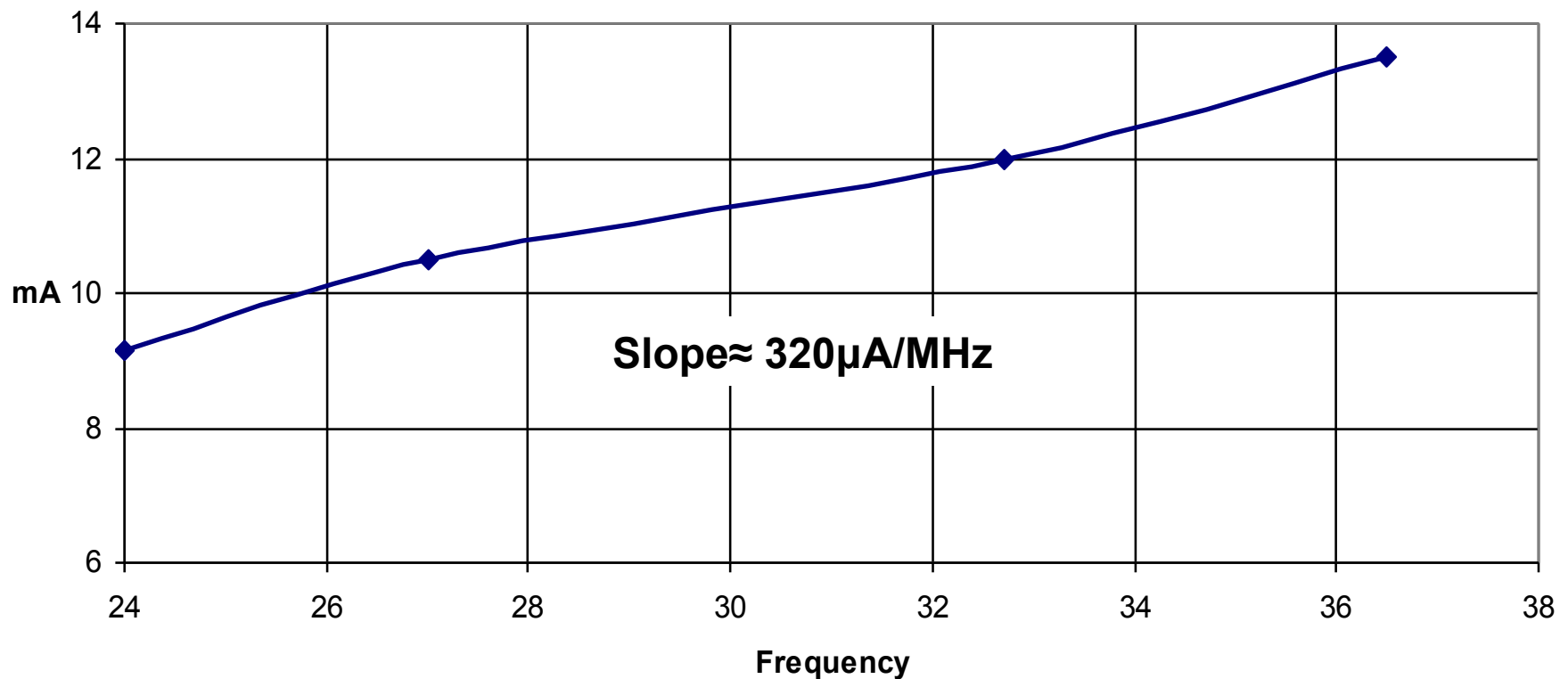
Extreme Low Temperature Test Data





Extreme Low Temperature 5X7 SMD

Supply current Vs. Frequency





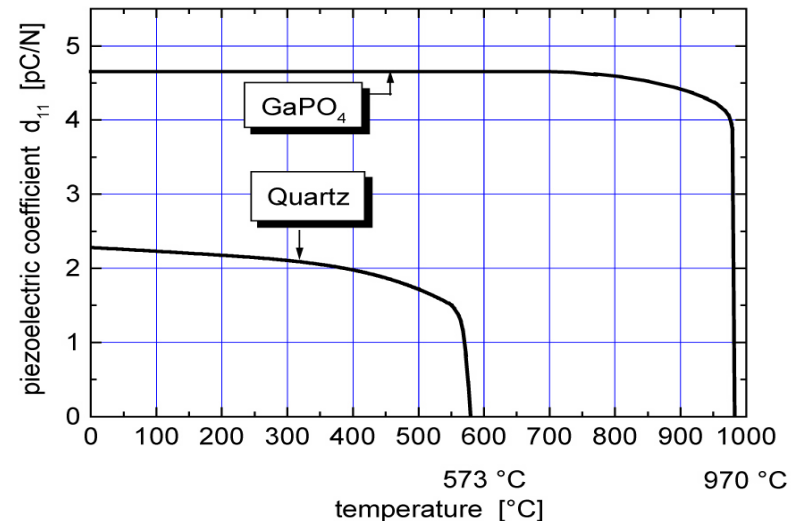
Extreme High Temperature Design Methodology

- Optimized crystal resonator material & cut
- Resonator holder & interconnect provisions
- Extreme high temperature resonator driver circuit
- Electro-mechanical interconnect system
- Material match for substrate & component attachment
- Monometallic bond/welding provisions
- Reinforced packaging to handle 90 bar ambient pressure
- Surface mountable enclosure (preferred)



Extreme High Temperature Design Approach

- **Conventional resonator material**
 - Quartz still performs at $T \sim 450^\circ\text{C}$ with increasing acoustical loss
 - Phase inversion happens in the low 500C
 - Both single & double rotation crystal cuts were evaluated
 - Double rotation delivers better performance compared to single rotation
 - Results show tolerances in the order of $\pm 0.5\%$ (-55 to +450)

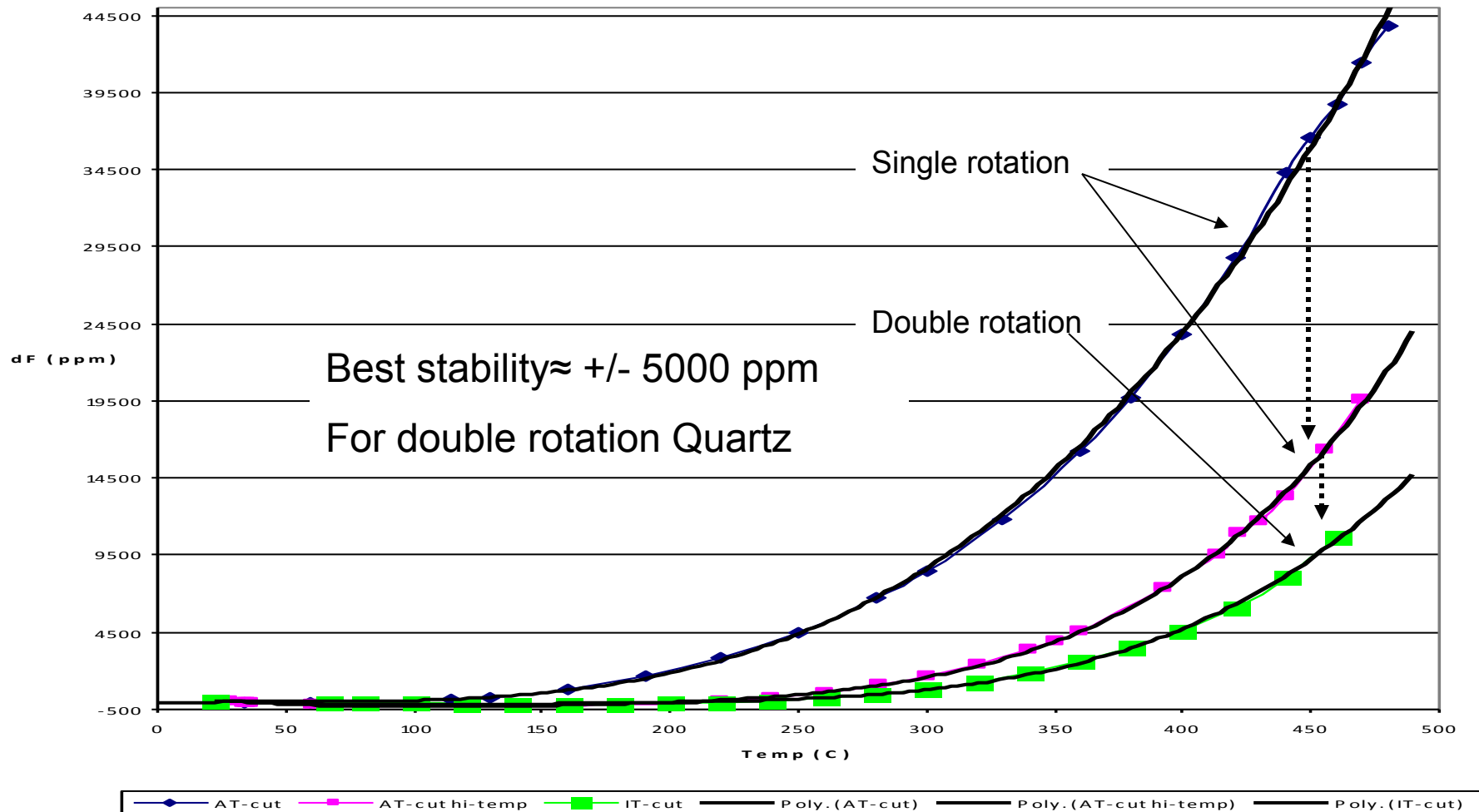


Quartz Resonator Results



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Extreme High Temp Test Data for Quartz





Extreme High Temperature Design Methodology

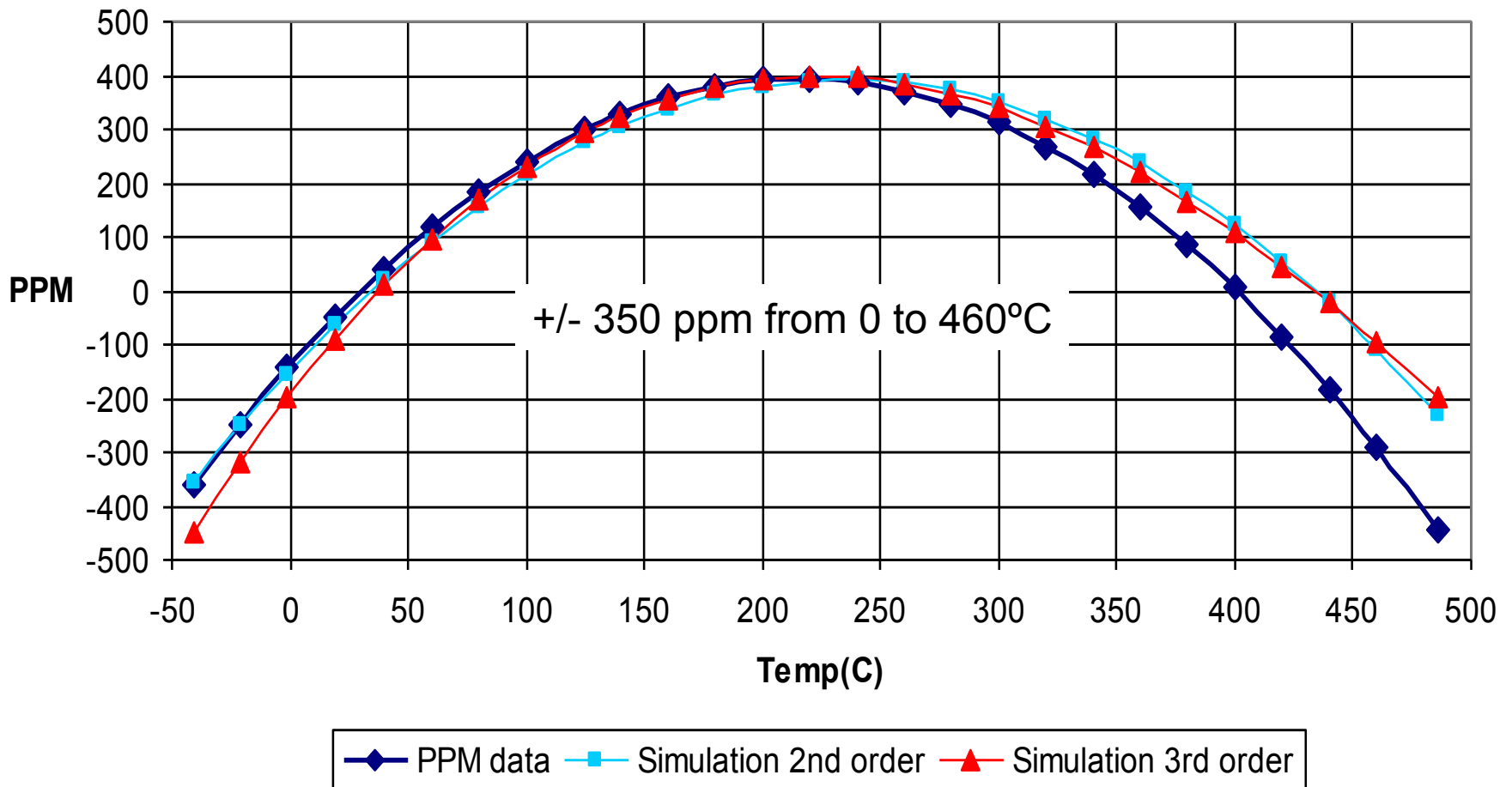
- **Non-Quartz resonator material**
 - Optimized Gallium Phosphate resonator as the suitable material
 - Very stable as Piezoelectric material with phase inversion at $T > 800^{\circ}\text{C}$
 - Performance over temperature is closer to parabolic with small 3rd order influence in the defined temperature range
 - Frequency stability vs. temperature can be optimized across a wide temperature range but altering the cut angle
 - Higher mechanical coefficient of coupling has the promise of smaller geometries at the same frequency compared to Quartz with larger pulling
 - Electrode configuration has been matched to the operating temperature to reduce surface tension and aging effects
 - Applications that can stand +/- 400 ppm tolerance (-40°C to $+460^{\circ}\text{C}$) can benefit from this design, more than 12 times improvement over Quartz
 - Further optimization will improve the stability to +/- 250~300 ppm depending on the temperature range

Ext High temp Stability Results



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Ribbon Mounted 6 MHz Frequency Stability

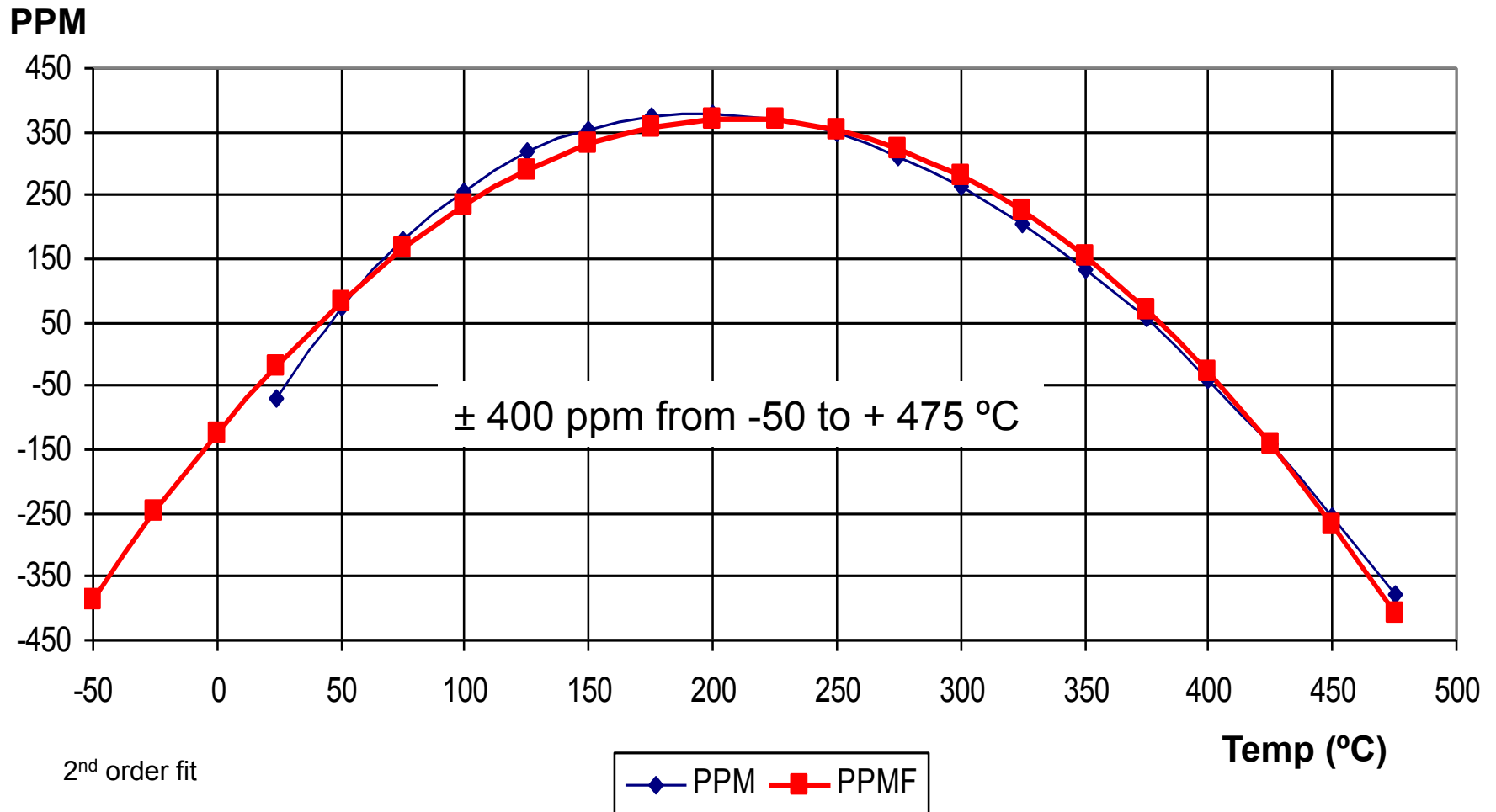


Ext High temp Stability Results



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Clip Mounted 6 MHz XTAL Stability

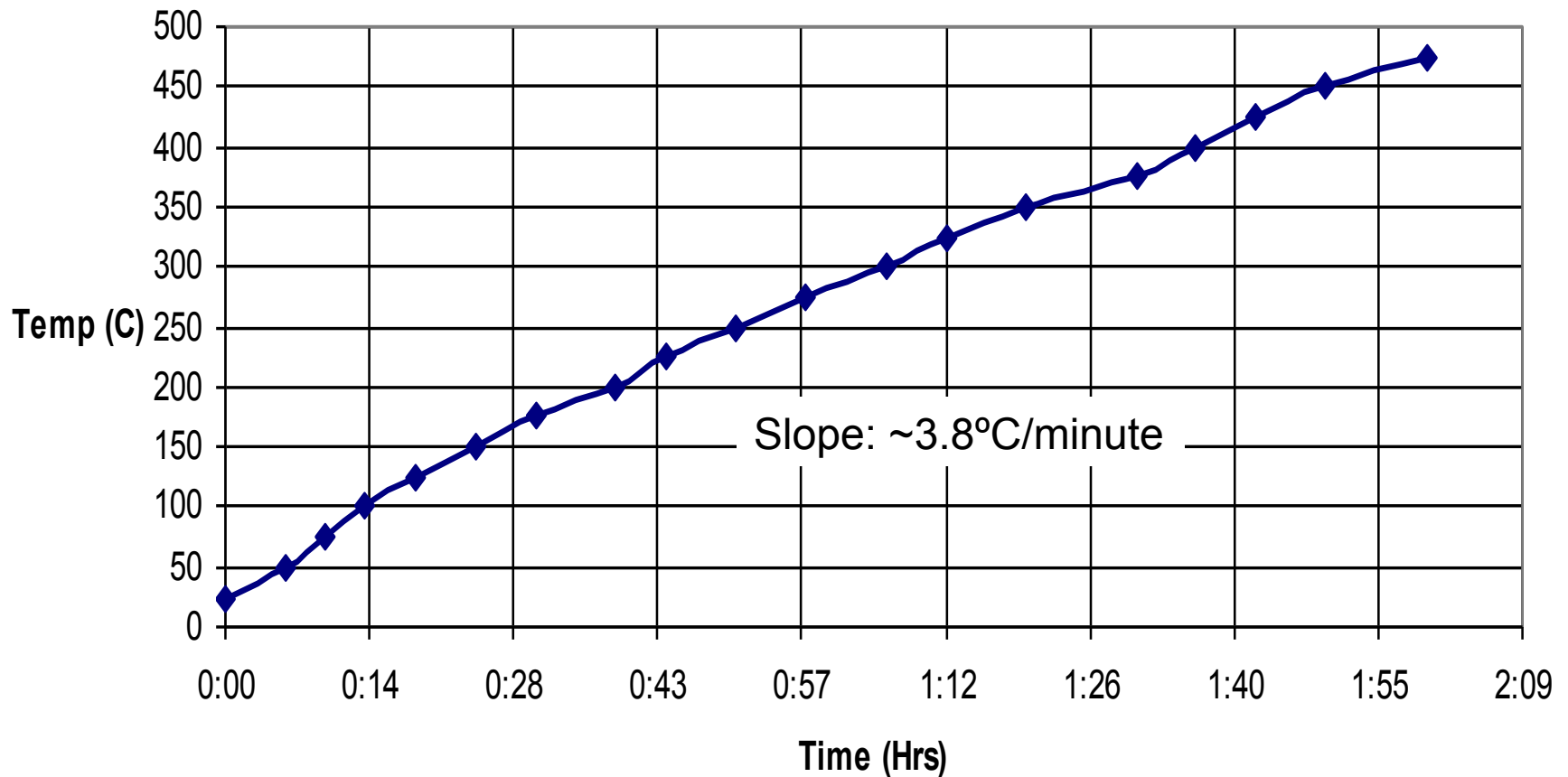


Test to 460°C & up



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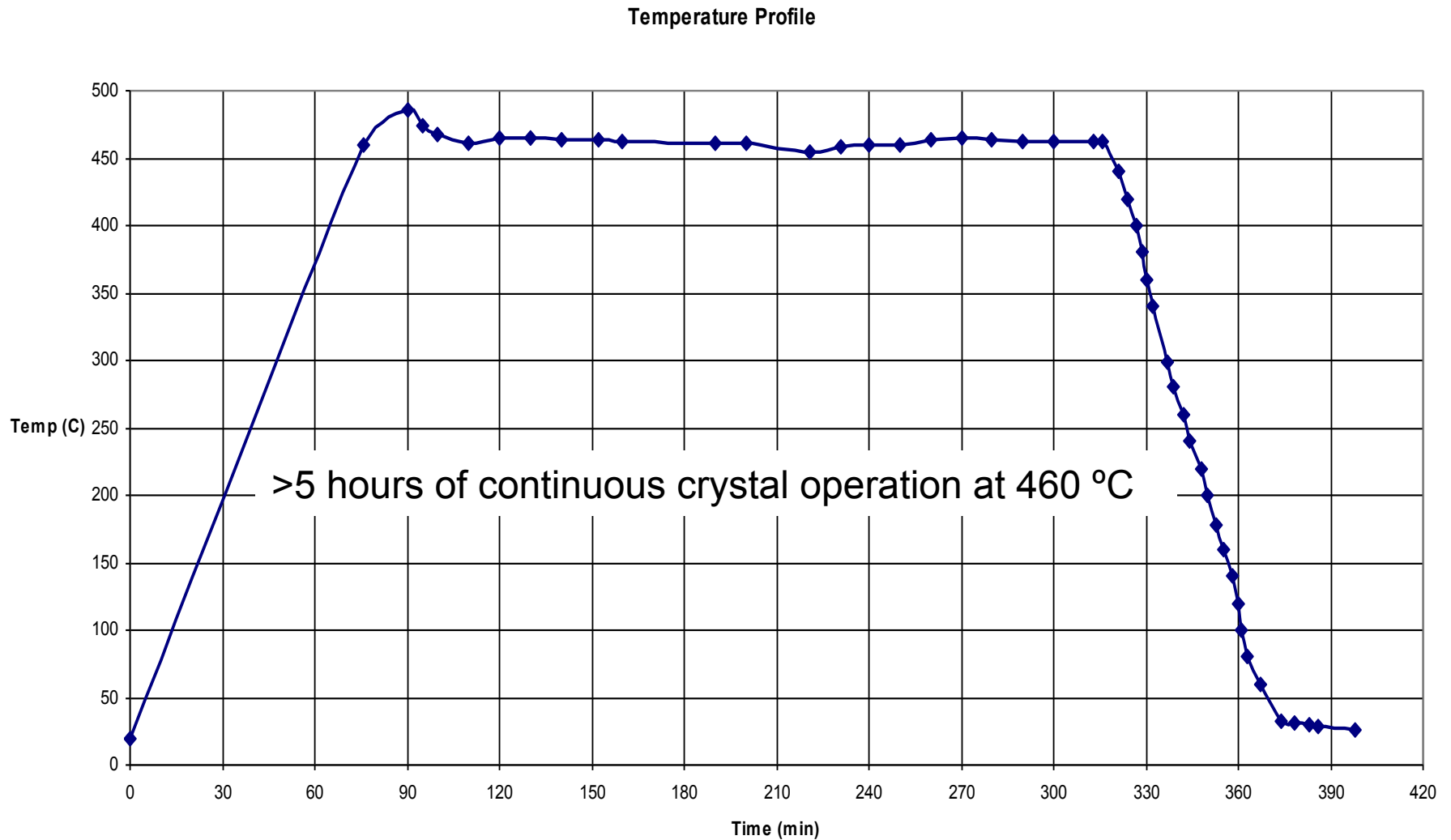
Thermal Ramp Profile



Extended Test @ 460°C



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Extreme High Temperature Crystal Driver

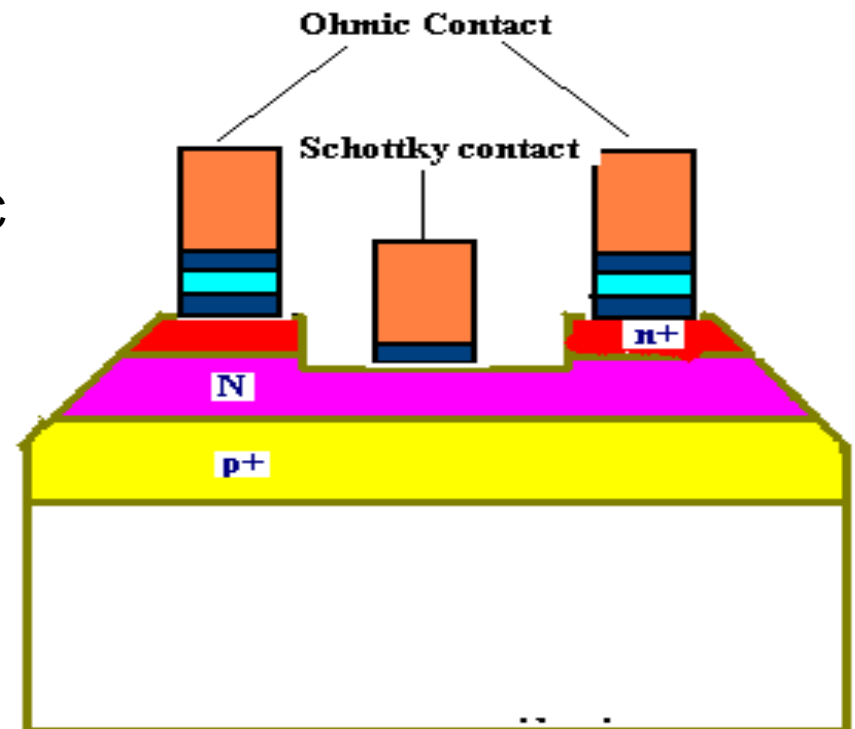
- **Active circuit attributes**

- Implemented on SiC(4H)
- Extremely low intrinsic carrier concentration
- Higher mobility (lateral) among SiC polytypes
- Ohmic contact
- Oxide growth process

Deep etching process

Schottky contact

Design optimization in progress

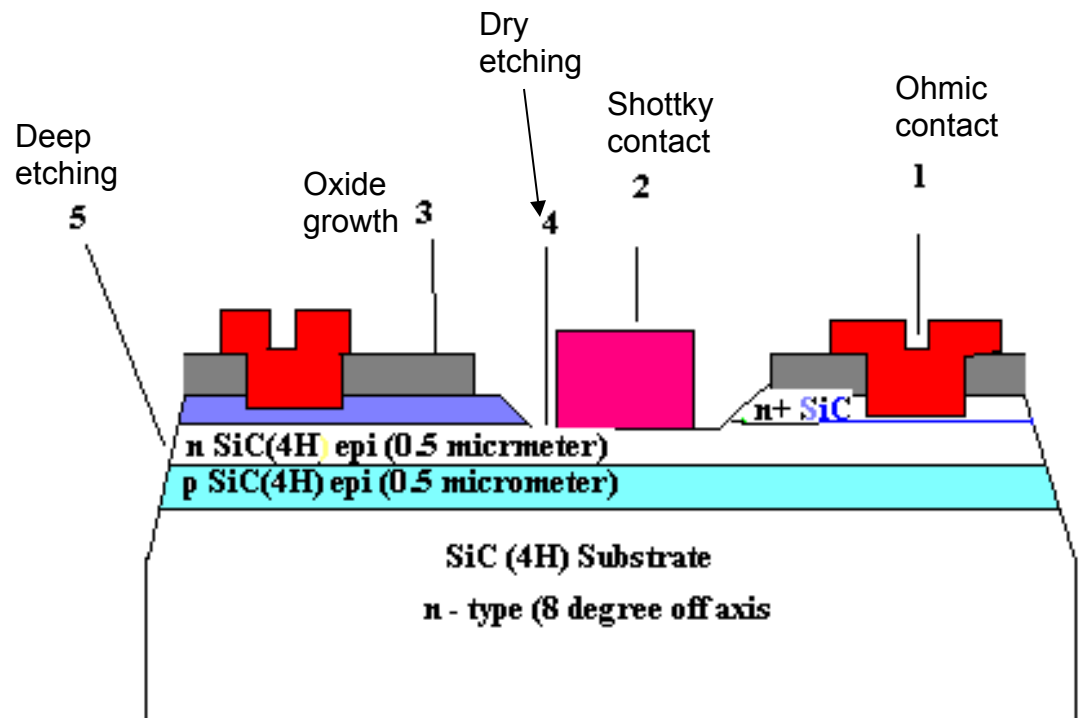




Extreme High Temperature Crystal Driver

- **Active circuit attributes**

- MESFET configuration on SiC(4H)
- Ti/Ni/Ti ohmic contact process
- Thermal growth process of SiO₂ over SiC
- Au plated pads will facilitate monometallic wire bonding to the rest of the circuit
- items 1&3 done





Extreme High Temp. SiC Process Optimization

Ohmic Contact layers

| Ti | Ni | Ti | Time/ Temp | Measurement Result |
|--------------|--------------|--------------|---|---|
| 300 Å | 300 Å | 100 Å | 1. 2' at 950 C 2. 2' at 1000 C 3. 2' at 1050 C | Ohmic, R_c ~ 180 Ohm Ohmic, R_c ~ 150 Ohm Ohmic, R_c ~ 110 Ohm |

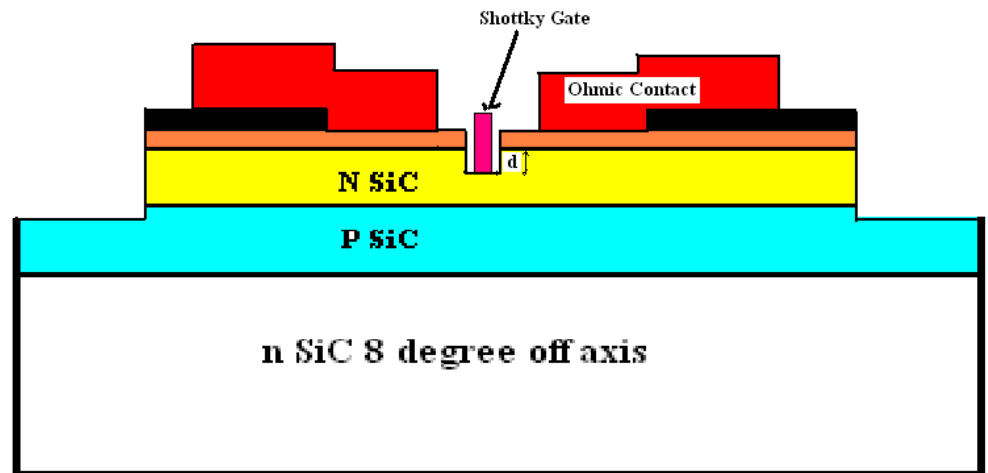
Oxidation method for SiO₂ growth over SiC

| Oxide Thickness (Å) | Method | Time (Hr) | Temperature (°C) |
|----------------------------|---------------|------------------|-------------------------|
| 50 (top layer) | Dry | 1 | 1140 |
| 500 (middle) | Wet | 3 | 1140 |
| 50 (buried) | Dry | 1.25 | 1140 |



Extreme High Temperature Crystal Driver

- SiC fabrication process optimization now in progress
- Etching process optimization to control the depth “d”
- First prototype MESFETS are expected by late July



Approximate layer structure



In Summary

- Frequency Management International (**FMI**) specializes in extreme environment and high performance frequency control products used in a wide range of applications
- We now have clear results for extreme low temperature and extreme high temperature crystal oscillator development
- We look forward to contributing to applications that would benefit from our capabilities, technologies and progress
- Our commitment and primary focus is our customers. We strive not only to meet, but to exceed our customers requirements and expectations in order to best support their objectives



***Excellence in Extreme Environment
Technologies***



Manufacturing Facilities & Capabilities

- Main facility in Huntington Beach, California with more than 16000 SF operating space including product specific manufacturing & test equipment, clean room upgrades
- Resonator manufacturing processes such as lap/Polish/contour, base plate, final plate and seal
- Hybrid manufacturing processes such as component attachment and wire bonding (ball and wedge), resonator packaging, resistance and seam welding
- Routine screen testing processes (Stability, aging, Burn-in (extreme temperature), thermal cycling, fine/gross leak testing)
- Tests guidelines per high reliability standards i.e. Mil 883, 202, 55310, etc.
- Outsource other tests to approved test facilities





Manufacturing Facilities & Capabilities

- Process control and documentation as a critical part of QA according to the leading industry certifications
- Wire bonding, epoxy attachment, vacuum deposition, vacuum baking, resistant and seam welding, marking, fine and gross leak testing, aging, burn-in, thermal cycling, moisture detection, automated testing (crystals, oscillators, hybrids), IT based automated order status and lot-traveler generation, formatted test data presentation, lead forming
- More than 100 years of engineering experience
- More than 60 years experience in the design & manufacture of crystals and hybrid oscillators

